

Fig.1

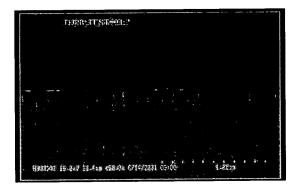


Fig.2

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ming the Same

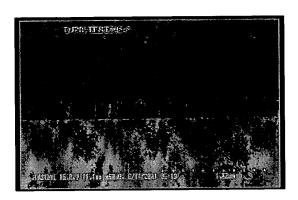
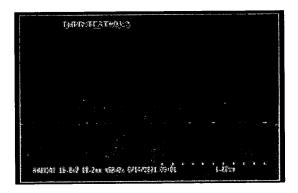
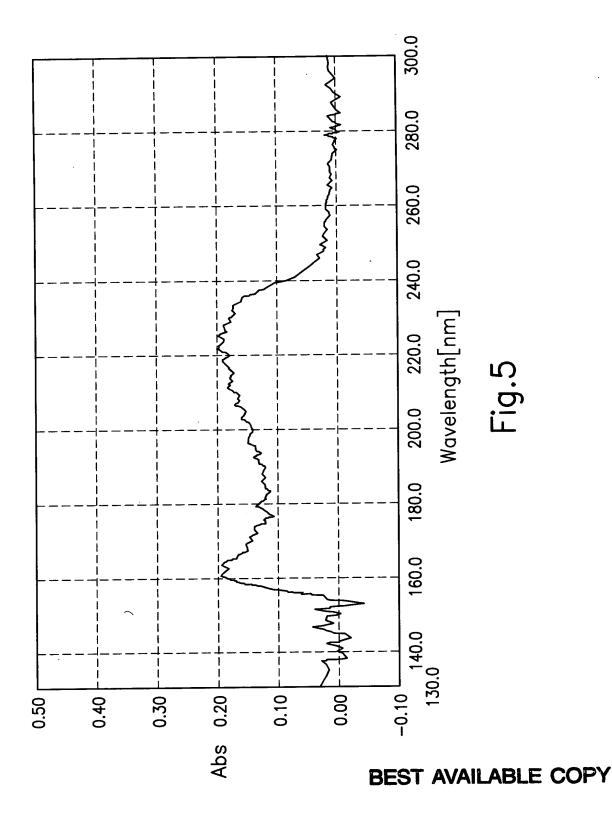


Fig.3



BEST AVAILABLE COPY Fig.4



Geun Su Lee et al.

Attorney Docket: 30205/38088
Photoresist Monomers, Polymers Thereof and Photoresist Compositions
Containing the Same